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**Coffee ring deposition in bands** SHREYAS MANDRE, Brown University, NING WU, Colorado School of Mines, JOANNA AIZENBERG, LAKSH-MINARAYANAN MAHADEVAN, Harvard University — Microscopic particles suspended in a liquid are transported and deposited at a contact line, as the contact line recedes due to evaporation. A particle layer of uniform thickness is deposited if the particle concentration is above a threshold; below this threshold the deposit forms periodic bands oriented parallel to the contact line. We present a model for the formation of these bands based on evaporation leading to the breakup of the thin liquid film near the contact line. The threshold results from a competition between evaporation speed and deposition speed. Using this model, we predict the thickness and length of the bands, making the control of patterned deposition possible.

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